

Your review of Nanoscale Horizons NH-COM-11-2019-000709.R1

Von: Nanoscale Horizons (onbehalf@manuscriptcentral.com)

An: NanoscaleHorizons@rsc.org

Datum: Montag, 17. Februar 2020, 04:00 GMT-6

Dear Reviewer

Thank you for providing a report on this manuscript submitted to Nanoscale Horizons. I appreciate the time and expertise you have contributed.

I am writing to inform you that after considering the comments and recommendations of all the reviewers my decision was to accept this manuscript for publication.

For your information any reports relating to this decision are provided below. Please note that this is an automated email sent to all the reviewers of this manuscript. This message should be treated as confidential.

I hope you find this information useful. Thank you for your support of Nanoscale Horizons.

Yours sincerely

Lucy Balshaw
Publishing Editor, Nanoscale Horizons
Royal Society of Chemistry

Pronouns: she/her.

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NH-COM-11-2019-000709.R1

Metal assisted chemical etching of silicon in gas phase: a nanofabrication platform for X-ray optics
Romano, Lucia; Kagias, Matias; Vila-Comamala, Joan; Jefimovs, Konstantins ; Tseng, Li-Ting; Guzenko, Vitaliy; Stampanoni, Marco

REVIEWER REPORT(S):

Referee: 2

Comments to the Author

The authors have addressed my comments properly and I believe that the manuscript is ready to be published.

Referee: 3

Comments to the Author

Thanks for considering the comments. I wish you success developing and your etching procedure.

Please note that for manuscripts which were accepted without further review this section will be blank.

If you need to contact the journal, please use the email address NanoscaleHorizons@rsc.org

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